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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09:927.068	08/09/2001	Jianhui Chen	TWI-13600	4935

7590

09/02/2003

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EXAMINER

STOCK JR, GORDON J

ART UNIT

PAPER NUMBER

2877

DATE MAILED: 09/02/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

## Office Action Summary

Application No.

09/927,068

Applicant(s)

CHEN ET AL.

Examiner

Gordon J Stock

Art Unit

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

### Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

### Status

- 1) ☐ Responsive to communication(s) filed on \_\_\_\_.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

### Disposition of Claims

- 4) ☒ Claim(s) 1-51 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-51 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_ are subject to restriction and/or election requirement.

### Application Papers

- 9) ☒ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 09 August 2001 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on \_\_\_\_ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

### Priority under 35 U.S.C. §§ 119 and 120

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- \* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

### Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☒ Information Disclosure Statement(s) (PTO-1449) Paper No(s) 0801.
- 4) ☐ Interview Summary (PTO-413) Paper No(s) \_\_\_\_.
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: \_\_\_\_\_

## DETAILED ACTION

### *Specification*

1. Applicant is reminded of the proper content of an abstract of the disclosure.

A patent abstract is a concise statement of the technical disclosure of the patent and should include that which is new in the art to which the invention pertains. If the patent is of a basic nature, the entire technical disclosure may be new in the art, and the abstract should be directed to the entire disclosure. If the patent is in the nature of an improvement in an old apparatus, process, product, or composition, the abstract should include the technical disclosure of the improvement. In certain patents, particularly those for compounds and compositions, wherein the process for making and/or the use thereof are not obvious, the abstract should set forth a process for making and/or use thereof. If the new technical disclosure involves modifications or alternatives, the abstract should mention by way of example the preferred modification or alternative.

The abstract should not refer to purported merits or speculative applications of the invention and should not compare the invention with the prior art.

Where applicable, the abstract should include the following:

- (1) if a machine or apparatus, its organization and operation;
- (2) if an article, its method of making;
- (3) if a chemical compound, its identity and use;
- (4) if a mixture, its ingredients;
- (5) if a process, the steps.

Extensive mechanical and design details of apparatus should not be given.

### *Claim Objections*

2. **Claim 48** is objected to for the following: the term, "the spectroscopic reflectometer," lacks antecedent basis. Correction is required.

**Claim 26** is objected to for being improperly dependent upon an apparatus claim.

Examiner has interpreted the claim as depending from claim 22. Correction is required.

### *Claim Rejections - 35 USC § 103*

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. **Claims 1-4, 8, 15-18, 21, 28-31, 35, 41-51** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Mikkelsen et al. (6,600,560)**.

As to **claim 1**, Mikkelsen in an optical measurement arrangement discloses: a first light source emitting radiation over a first broadband emission spectrum, a halogen lamp comprising xenon and a second light source being substantially transparent over a portion of the first broadband emission spectrum, the infrared portion, a deuterium lamp (col. 6, lines 5-15); a first optical system for directing a portion of the radiation emitted from the first light source through the second light source; a second optical system that produces a second image of the second light source (Fig. 1); an aperture stop (Fig. 1; 5); a third optical system for focusing the radiation transmitted by the aperture stop on the sample (Fig. 1). As for the focusing and the focal positions, Mikkelsen is silent; however, he discloses the sources sharply imaged in the plane of the aperture stop (col. 6, lines 25-30). Therefore, it would be obvious to one skilled in the art that the first optical system forms a first image of the first light source at a first focal position substantially on the second light source and the second optical system produces a second image of the second light source at a second focal position along with the image of the first light source, for the sources are images sharply on the plane of the aperture stop.

For **claim 2** Mikkelsen discloses the first and second light sources are selected from the group consisting of incandescent and discharge sources, a halogen lamp and deuterium lamp (col. 6, lines 5-15).

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For **claims 3-4** the lamps have emission spectra covering uv-vis and visible, deuterium and halogen lamps (col. 6, lines 5-15).

For **claims 8 and 15** the first light source is a xenon filled halogen lamp and the second light source is a deuterium lamp (col. 6, lines 5-15).

For **claim 16** the first, second and third optical systems employ at least one element consisting of transmissive and polarizing optics (Fig. 1; col. 6, lines 5-67).

As for **claim 17** the first focal position and second source position are substantially coincident for both are sharply imaged on the plane of the aperture stop.

For **claim 18** Mikkelsen does not mention the image of the aperture at the sample, but the sources are imaged sharply on the plane of the aperture that comprises the measurement beam (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture stop.

For **claim 21** Mikkelsen discloses the system is an ellipsometer (col. 8, lines 58-60).

For **claim 28** Mikkelsen in an optical measurement arrangement discloses: a first light source emitting radiation over a first broadband emission spectrum, a halogen lamp comprising xenon and a second light source being substantially transparent over a portion of the first broadband emission spectrum, the infrared portion, a deuterium lamp (col. 6, lines 5-15); a first optical system for directing a portion of the radiation emitted from the first light source through the second light source; a second optical system that produces a second image of the second light source (Fig. 1); an aperture stop (Fig. 1; 5); a third optical system for focusing the radiation

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transmitted by the aperture stop on the sample (Fig. 1); a detection system that also analyzes (col. 8, lines 20-25). Mikkelsen does not mention a processor but suggests a processor because there is a rapid readout of spectra (col. 8, lines 55-60). Examiner takes official notice that processors are well known in the art for evaluating data. Therefore, it would be obvious to one skilled in the art at the time the invention was made to have the system comprise a processor in order to evaluate the signals detected. As for the focusing and the focal positions, Mikkelsen is silent; however, he discloses the sources sharply imaged in the plane of the aperture stop (col. 6, lines 25-30). Therefore, it would be obvious to one skilled in the art that the first optical system forms a first image of the first light source at a first focal position substantially on the second light source and the second optical system produces a second image of the second light source at a second focal position along with the image of the first light source, for the sources are images sharply on the plane of the aperture stop.

For **claim 29** Mikkelsen discloses the first and second light sources are selected from the group consisting of incandescent and discharge sources, a halogen lamp and deuterium lamp (col. 6, lines 5-15).

For **claims 30-31** the lamps have emission spectra covering uv-vis and visible, deuterium and halogen lamps (col. 6, lines 5-15).

For **claims 35 and 41** the first light source is a xenon filled halogen lamp and the second light source is a deuterium lamp (col. 6, lines 5-15).

For **claim 42** the first, second and third optical systems employ at least one element consisting of transmissive and polarizing optics (Fig. 1; col. 6, lines 5-67).

For **claim 43** the first focal position and second source position are substantially coincident for both are sharply imaged on the plane of the aperture stop.

For **claim 44** Mikkelsen does not mention the image of the aperture at the sample, but the sources are imaged sharply on the plane of the aperture that comprises the measurement beam (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture stop.

For **claim 45** Mikkelsen discloses the third optical system segregate polarization states (col. 3, lines 35-45; col. 6, lines 58-67; col. 7, lines 1-45). As for a polarized image of the aperture at the sample Mikkelsen is silent. However, the sources are imaged sharply on the plane of the aperture that comprises the measurement beam that is polarized (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was polarizedly imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture and is polarized by the system.

For **claim 46** Mikkelsen discloses a Rochon prism (col. 7, lines 58-65).

For **claim 47** Mikkelsen discloses the system is an ellipsometer (col. 8, lines 58-60).

For **claim 48** Mikkelsen is silent concerning polarized beam spectroscopic reflectometry or spectroscopic reflectometry. However, Mikkelsen teaches that optical material properties and surface structure may be calculated (col. 7, lines 30-40) and that ellipsometric and spectroscopic investigations may be performed (col. 8, lines 58-60). Therefore, it would be obvious to one

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skilled in the art that the system can consist of a polarized beam spectroscopic reflectometer, for polarized beam spectroscopic reflectometry is a type of spectroscopic investigation that derives optical material properties and surface structure information.

As for **claims 49-51**, the system comprises an ellipsometer that detects changes in polarization states at differing angles of incidence (col. 7, lines 25-40; col. 8, lines 58-61).

5. **Claims 5, 9, 11, 12, 32, 36, 37, 38** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Mikkelsen et al. (6,600,560)** in view of **Piwonka-Corle et al. (5,910,842)** and **Carlson et al. (4,771,629)**.

As for **claim 5 and 32** Mikkelsen is silent concerning the spectra of both sources being the same, but discloses a xenon filled halogen lamp and deuterium lamp (col. 6, lines 5-15). Carlson in a system for chemical analysis teaches that a xenon lamp and deuterium lamp have similar wavelength ranges (col. 11, lines 15-20). And Piwonka-Corle in an ellipsometry method teaches that the xenon arc lamp is preferable light source for flatter spectrum than a deuterium lamp that suggests similar spectral ranges (col. 6, lines 50-60). Therefore, it would be obvious to one skilled in the art that the sources have similar wavelengths for xenon lamps have similar spectral characteristics as a deuterium lamp.

As for **claims 9 and 36** Mikkelsen is silent concerning the first light source being a deuterium lamp and the second light source being from xenon. However, he discloses a xenon filled halogen lamp and deuterium lamp (col. 6, lines 5-15). Carlson in a system for chemical analysis teaches that a xenon lamp and deuterium lamp are functionally equivalent (col. 11, lines 15-20). And Piwonka-Corle in an ellipsometry method teaches that the xenon arc lamp is a preferable light for flatter spectrum than a deuterium lamp that suggests equivalence. Therefore,



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it would be obvious to one skilled in the art at the time the invention was made to have the first and second light sources comprise a deuterium lamp and xenon lamp respectively, for they are recognized as functional equivalents of each other.

As for **claims 11 and 37** Mikkelsen is silent concerning the lamps being xenon arc lamps. Carlson in a system for chemical analysis teaches that a xenon lamp and deuterium lamp are functionally equivalent (col. 11, lines 15-20). And Piwonka-Corle in an ellipsometry method teaches that the xenon arc lamp is a preferable light for flatter spectrum than a deuterium lamp that suggests equivalence. Therefore, it would be obvious to one skilled in the art at the time the invention was made to have the first and second light sources comprise xenon arc lamps, for they are recognized as functional equivalents of deuterium lamps and xenon lamps.

As for **claims 12 and 38** Mikkelsen is silent concerning both sources being deuterium lamps. However, Carlson in a system for chemical analysis teaches that a xenon lamp and deuterium lamp are functionally equivalent (col. 11, lines 15-20). And Piwonka-Corle in an ellipsometry method teaches that the xenon arc lamp is a preferable light for flatter spectrum than a deuterium lamp that suggests equivalence. Therefore, it would be obvious to one skilled in the art at the time the invention was made to have the first and second light sources comprise deuterium lamps, for deuterium lamps are recognized as functional equivalents of xenon lamps.

6. **Claims 6, 10, 13, 19, 20, 22-27, 33, and 39** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Mikkelsen et al. (6,600,560)** in view of **Carlson et al. (4,771,629)**.

As for **claims 6 and 33**, Mikkelsen is silent concerning the differing spectra of the sources, but the two sources are a deuterium lamp and a halogen lamp that may be filled with krypton or xenon (col. 6, lines 1-15). Carlson teaches that deuterium lamps differ from halogen

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bulbs (col. 11, lines 10-20). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the two spectra of the light sources differ for the wavelength ranges of a halogen lamp versus a deuterium lamp differ.

As for **claims 10, 13, 39**, Mikkelsen is silent concerning a tungsten lamp for the first light source. However, Carlson teaches that halogen and tungsten bulbs are equivalent (col. 11, lines 10-20). Therefore, it would be obvious to one skilled in the art at the time to have the first light source be a tungsten lamp, for the tungsten lamp is an art-recognized equivalent to a halogen lamp.

For **claim 19** Mikkelsen discloses the third optical system segregate polarization states (col. 3, lines 35-45; col. 6, lines 58-67; col. 7, lines 1-45). As for a polarized image of the aperture at the sample Mikkelsen is silent. However, the sources are imaged sharply on the plane of the aperture that comprises the measurement beam that is polarized (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was polarizedly imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture and is polarized by the system.

For **claim 20** Mikkelsen discloses a Rochon prism (col. 7, lines 58-65).

For **claim 22** Mikkelsen discloses a method of using an apparatus: a first light source emitting radiation over a first broadband emission spectrum, a halogen lamp comprising xenon and a second light source being substantially transparent over a portion of the first broadband emission spectrum, the infrared portion, a deuterium lamp (col. 6, lines 5-15); a first optical system for directing a portion of the radiation emitted from the first light source through the

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second light source; a second optical system that produces a second image of the second light source (Fig. 1); an aperture stop (Fig. 1; 5); a third optical system for focusing the radiation transmitted by the aperture stop on the sample (Fig. 1). As for the focusing and the focal positions, Mikkelsen is silent; however, he discloses the sources sharply imaged in the plane of the aperture stop (col. 6, lines 25-30). Therefore, it would be obvious to one skilled in the art that the first optical system forms a first image of the first light source at a first focal position substantially on the second light source and the second optical system produces a second image of the second light source at a second focal position along with the image of the first light source, for the sources are images sharply on the plane of the aperture stop.

Mikkelsen is silent concerning the differing spectra of the sources, but the two sources are a deuterium lamp and a halogen lamp that may be filled with krypton or xenon (col. 6, lines 1-15). Carlson teaches that deuterium lamps differ from halogen bulbs (col. 11, lines 10-20). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the two spectra of the light sources differ for the wavelength ranges of a halogen lamp versus a deuterium lamp differ.

As for **claim 23** Mikkelsen discloses the first and second light sources are selected from the group consisting of incandescent and discharge sources, a halogen lamp and deuterium lamp (col. 6, lines 5-15). The lamps have emission spectra covering uv-vis and visible, for they are deuterium and halogen lamps (col. 6, lines 5-15).

As for **claim 24** the first, second and third optical systems employ at least one element consisting of transmissive and polarizing optics (Fig. 1; col. 6, lines 5-67).

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As for **claim 25** Mikkelsen does not mention forming an image of the aperture at the sample, but the sources are imaged sharply on the plane of the aperture that comprises the measurement beam (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture stop.

As for **claim 26** Mikkelsen is silent about a polarized image of the aperture at the sample. However, the sources are imaged sharply on the plane of the aperture that comprises the measurement beam that is polarized (col. 6, lines 25-30; lines 45-60). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the aperture stop was polarizedly imaged on the sample for the measurement beam comprises the sharp images of the light sources on the plane of the aperture and is polarized by the system.

As for **claim 27** Mikkelsen discloses the system is an ellipsometer (col. 8, lines 58-60).

7. **Claims 7, 14, 34, and 40** are rejected under 35 U.S.C. 103(a) as being unpatentable over **Mikkelsen et al. (6,600,560)** in view of **Carlson et al. (4,771,629)** and further in view of **Sei et al. (WO 01/06173)**.

As for **claims 7, 14, 34, 40**, Mikkelsen is silent concerning the differing spectra of the sources, but the two sources are a deuterium lamp and a halogen lamp that may be filled with krypton or xenon (col. 6, lines 1-15). Carlson teaches that deuterium lamps differ from halogen bulbs (col. 11, lines 10-20). Therefore, it would be obvious to one skilled in the art at the time the invention was made that the two spectra of the light sources differ for the wavelength ranges of a halogen lamp versus a deuterium lamp differ. As for having the first light source comprise a

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tungsten-halogen lamp, Mikkelsen in view of Carlson is silent. However, Sei in a composite light source teaches the equivalence of a halogen lamp and a metal halide lamp (lines 10-12 of page 18 of translation). Therefore, it would be obvious to one skilled in the art at the time the invention was made to substitute the halogen light source with a tungsten-halogen source, for the halogen lamp and metal-halide source are art recognized equivalents in composite light sources.

### *Conclusion*

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure:

U.S. Patent 4,526,470 to Kaye (specifically, col. 13, lines 25-35)

U.S. Patent 6,268,917 to Johs

U.S. Patent 6,504,608 to Hallmeyer et al.

### *Fax/Telephone Numbers*

If the applicant wishes to send a fax dealing with either a proposed amendment or a discussion with a phone interview, then the fax should:

- 1) Contain either a statement "DRAFT" or "PROPOSED AMENDMENT" on the fax cover sheet; and
- 2) Should be unsigned by the attorney or agent.

This will ensure that it will not be entered into the case and will be forwarded to the examiner as quickly as possible.

*Papers related to the application may be submitted to Group 2800 by Fax transmission. Papers should be faxed to Group 2800 via the PTO Fax machine located in Crystal Plaza 4. The form of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (November 15, 1989). The CP4 Fax Machine number is: (703) 308-7722*

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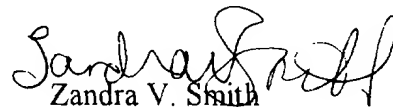
Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gordon J. Stock whose telephone number is (703) 305-4787.

The examiner can normally be reached on Monday-Friday, 10:00 a.m. - 6:30 p.m.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

gs

August 22, 2003



Zandra V. Smith

Primary Examiner

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